

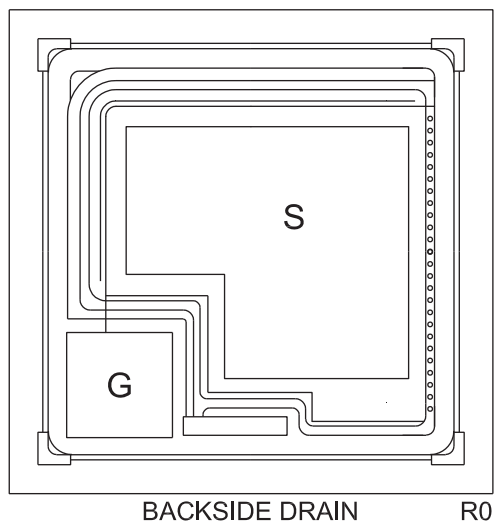
PROCESS CP794R
Small Signal MOSFET Transistor
P - Channel Enhancement-Mode Transistor Chip



PROCESS DETAILS

Die Size	15.7 x 15.7 MILS
Die Thickness	3.9 MILS
Gate Bonding Pad Area	3.9 x 3.9 MILS
Source Bonding Pad Area	9.1 x 8.1 MILS
Top Side Metalization	Al-Si - 35,000Å
Back Side Metalization	Au - 12,000Å

GEOMETRY



GROSS DIE PER 6 INCH WAFER

95,400

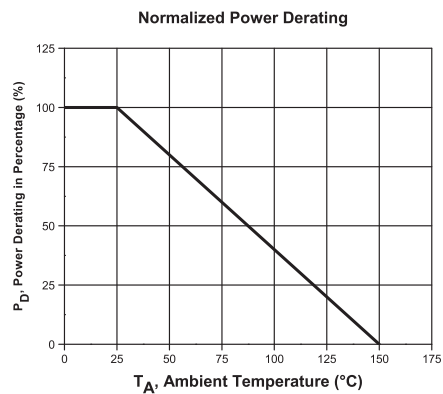
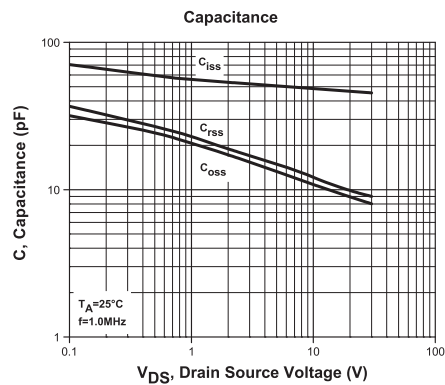
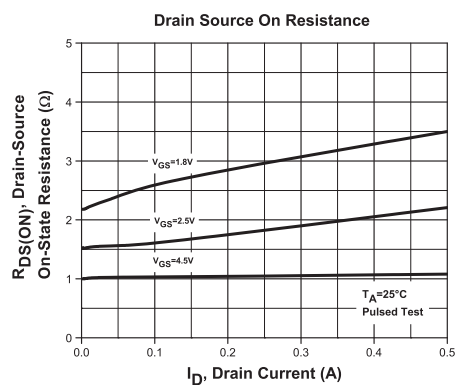
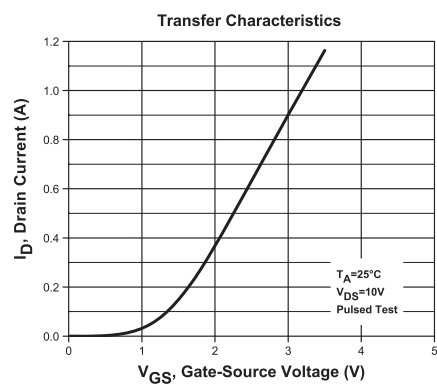
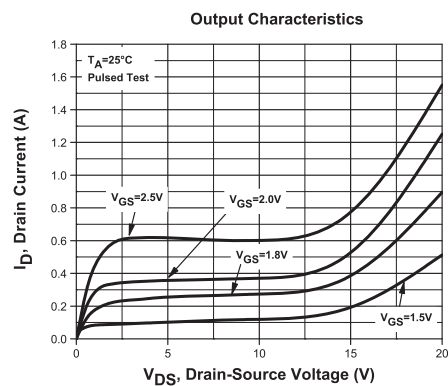
PRINCIPAL DEVICE TYPES

CEDM8004
CMLM0584
CMLDM7484

R0 (29-July 2010)

PROCESS CP794R

Typical Electrical Characteristics



R0 (29-July 2010)